



# 2013 International Workshop on EUV Lithography

Maui, Hawaii

June 10-14, 2013

## FIRST CALL FOR PAPERS

We are inviting presentations and poster papers for the 2013 International Workshop on EUV Lithography to be held from June 10-14, 2013, in Makena Beach Golf Resort, Maui, Hawaii, USA. This workshop, now in its sixth year, is focused on fundamental science of EUV Lithography (EUVL). Smaller group setting suitable for networking and brainstorming, with a focus on fundamentals, sets this conference apart from other larger conferences focused on commercial aspects of EUVL.

Technology review papers and papers with innovative approaches to address current EUV Lithography related technical challenges are encouraged. EUV Lithography related topics covered under this workshop are: source, source collector module, exposure tools, mask, optics, resist, contamination, metrology, patterning and cost of ownership. Papers on extension of lithography to Beyond EUV (BEUV) wavelength of 6.x nm are also welcome.

On June 10, 2013 EUV Lithography Short Course will be offered. The workshop will start with registration and registration on June 11<sup>th</sup> and will be followed by presentations, panel discussions and a poster session on June 12<sup>th</sup> and 13<sup>th</sup>. The workshop will conclude with a Steering Committee meeting on June 14<sup>th</sup>, 2013, which is open to all workshop attendees. The keynote speakers for the 2013 workshop will be announced soon on our website [www.euvlitho.com](http://www.euvlitho.com).

The 2013 International Workshop on EUV Lithography is organized by EUV Litho, Inc.

### Instructions for Submissions and Deadlines

Please submit abstracts of less than 200 words. Indicate whether an oral or poster paper is preferred. Please include full name, email, and mailing address for all authors. Abstracts should be submitted via email to [abstracts@euvlitho.com](mailto:abstracts@euvlitho.com)

The deadline for abstract submission is March 9, 2013. Abstracts will be evaluated by the workshop's technical Steering Committee for inclusion in the workshop. Authors will be notified by March 16, 2013, if their abstracts have been accepted for an oral or poster paper.

### Contact Information

For meeting-related issues please contact: [meeting.planner@euvlitho.com](mailto:meeting.planner@euvlitho.com)

For technical questions, please contact: [vivek.bakshi@euvlitho.com](mailto:vivek.bakshi@euvlitho.com)